

INFORMATION DISCLOSURE STATEMENT

Applicant : Hayashi et al.

App. No : 10/565,696

Filed : January 24, 2006

For : RESIN FOR RESIST, POSITIVE
RESIST COMPOSITION, AND
METHOD OF FORMING RESIST
PATTERN

Examiner : Huhn, Richard A.

Art Unit : 1796

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June 2, 2009

(Date)

Neil S. Bartfeld, Ph.D., Reg. No. 39,901

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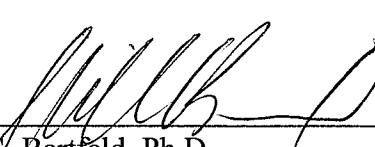
Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 6 (six) references to be considered by the Examiner. Also enclosed are 4 (four) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed after the mailing date of a final action or after the mailing date of a Notice of Allowance. This Statement is accompanied by the fee set forth in 37 C.F.R. § 1.17(p). The Commissioner is hereby authorized to charge any additional fees which may be required or to credit any overpayment to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 6/2/09By: 

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